



R. Raman¹, D. Gates², T.R. Jarboe¹, D. Mueller², M.J. Schaffer³, R. Maqueda⁴, B.A. Nelson¹, M. Bell², R. Bell², R. Ewig¹, E. Fredrickson², J. Hosea², S. Jardin¹, H. Ji², R. Kaita², S.M. Kaye², H. Kugel², L.Lao³, B. Leblanc², R. Maingi⁶, J. Menard², M. Ono², D. Orvis¹, F. Paoletti⁵, S. Paul², M. Peng⁶, S. Sabbagh⁵, C.H. Skinner², J.B. Wilgen⁶, S. Zweben² and the NSTX Research Team ¹ University of Washington, Seattle, WA ² Princeton Plasma Physics Laboratory, Princeton, NJ ³ General Atomics, San Diego, CA ⁴ Los Alamos National Laboratory, Los Alamos, NM ⁵ Columbia University, New York, NY ⁶ Oak Ridge National Laboratory, Oak Ridge, TN

NSTX - PAC-10

February 8-9, 2001 Princeton Plasma Physics Laboratory, Princeton, NJ

* Work supported by U.S. DOE contract numbers. DE-AC02-76CH03073, DE-AC05-00R22725, DE-AC03-99ER54463, DE-FG02-99ER54524, DE-FG03-99ER54519, W-7405-ENG-36

Raman, PAC-10



- Obtained CHI injector current multiplication of 10 at 26kA
- Produced non-inductive, long pulse (200ms) discharges
- Sustained discharges at 1mTorr vessel neutral pressures. NSTX ohmic discharges operated at similar vessel neutral pressures.
- There is no fundamental difficulty in applying CHI electrical systems to a large plasma device.

Questions and recommendations from PAC-9

Summary of CHI startup results covering:

- Gas fill
- Plasma density, and electron temperature issues in forming toroidal current
- Use of inductive currents applied late in the discharge may also help to establish the CHI driven current in an equilibrium.
- Clarify goals of CHI target plasma for near-term and long term.

CHI operated at vessel neutral pressures compatible with Ohmic operation



Need to move CHI plasma core region to be in line of sight with Thomson for density and temperature measurement

High current configuration —► Preferred configuration



Vacuum flux plots with <u>added</u> plasma current filaments (not EFIT) Raman, PAC-10

Near Term Goals (now to 9/02)

- Establish flux closure (may need good boundary shape control)
- Test OH induction on a high current CHI discharge
- Test CHI edge current on an OH discharge

- EFIT with open field line currents in private flux region
- Reduce absorber arcs
- Initiate feedback control tests

Absorber arc suppression (D. Gates)

- PF1au to create absorber null
- Higher poloidal field in absorber
- Study options for additional field null control coils
- Redesign absorber insulator region
 - Insulator on high field side

HIT-II absorber design allows good boundary shape control



Add CHI to inductive plasma (D. Mueller)

- Can be run independent of arc problem
- Study CHI current drive and impact on transport
- Add auxiliary heating

Demonstration of closed flux (R. Raman)

- Plasma shape control, absorber arc control, TF scan, gas puff scan, OH induction
- Peaked Thomson profiles + EFIT
- Modify EFIT to include private flux current (M. Schaffer, L. Lao)
- Measure poloidal (halo) current in injector region to constrain EFIT

Begin feedback control development (B.A. Nelson)

- Absorber null control
 - Real-time null reconstruction technique
- Plasma current control
- Boundary control
- Note: CHI control requires conceptual development not well formulated as with Ohmic plasma control

Longer term goals

- Implement fast PF coils for absorber field reduction
- Redesign absorber (improved insulator and electrode shape)
- Establish plasma start-up without the OH coil
- Optimize CHI edge current drive on a OH target
- Reduce Ohmic flux consumption
- Consider operation with no external TF for FRC formation test.
- Implement full feedback control
- Detailed measurements using edge probe, MSE, Fast Camera to understand flux closure mechanisms
 - Conduct divertor heat load studies
 - Routine EFIT and TSC

Raman, PAC-10